Support information for

Sulfurization induced surface constitution and its correlation to the performance of solution-processed Cu₂ZnSn(S,Se)₄ solar cells

Jie Zhong^{1,2}, Zhe Xia^{1,2}, Miao Luo^{1,2}, Juan Zhao³, Jie Chen^{1,2}, Liang Wang^{1,2}, Xinsheng Liu^{1,2}, Ding-Jiang Xue^{1,2}, Yi-Bing Cheng^{1,3}, Haisheng Song^{1,2}, Jiang Tang^{1,2*} ¹⁾ Wuhan National Laboratory for Optoelectronics (WNLO), and ²⁾ School of Optical and Electronic Information, Huazhong University of Science and Technology (HUST), Wuhan, 430074, China, ³⁾ Department of Materials Engineering, Monash University, VIC 3800 Australia * Corresponding author: jtang@mail.hust.edu.cn



Figure S1. Performances of CZTSSe solar cell annealed at different sulfur content.

Sulfur	РСЕ	Voc	Jsc	FF	R voc	R Isc
10 mg	0.319	0.502	2.435	26.1	523	582
7 mg	3.69	0.391	20.7	45.7	14.8	283
6 mg	6.4	0.461	27.5	50.3	12.4	406
5 mg	4.47	0.445	21.6	46.5	16.7	412
4 mg	1.16	0.246	17.4	27.03	31.8	42.42
2 mg	0.544	0.272	7.3	27.3	76	109
1 mg	0.05	0.055	3.9	24.9	32.3	37.6
<1mg	Short circuited					

Table S1. Record efficiencies for samples annealed with different amount of S additions



Figure S2. SEM surface morphologies of CZTSSe films annealed with different amount of S powders (1-10 mg): (a), S1 (1 mg); (b), S2 (4 mg); (c), S3 (6 mg) and (d), S4 (10 mg).



Figure S3. Capacitance-votage profiles of samples S3 and S2. The calculated depletion zone widths and doping densities are 305 nm, 181 nm and 9.7×10^{15} , 1.1×10^{17} for S3 and S2, respectively. The doping density ($N_{A,P}$) in CZTSSe film are calculated using the equation:

$$N_{A,p} = \frac{-2\varepsilon_{r,n}N_{D,n}}{\left(\frac{d(1/C_j^2)}{dV}\right)qA^2\varepsilon_0\varepsilon_{r,n}\varepsilon_{r,p}N_{D,n} + 2\varepsilon_{r,p}}$$

 C_m was used instead of C_j for the calculation, leading to an overestimated $N_{A,P}$ value. For the CdS film, the relative dielectric constant ($\varepsilon_{r,n}$) of 9 and donor concentration ($N_{D,n}$) of 1×10^{17} cm⁻³.¹ The CZTSSe relative dielectric constant ($\varepsilon_{r,p}$) is 8.² The V_{bi} used for $W_d = (2\varepsilon_o\varepsilon_s V_{bi}/qN_A)^{1/2}$ is obtained by horizontal intercept by the linearly fitting the plot of A^2/C^2 against voltage at zero bias.



Figure S4. Capacitance-voltage (C-V) profiling and drive level capacitance profiling (DLCP) of S3.³ C-V and DLCP measurement under under forward bias is introduced to study acceptor doping density in the depleted CZTSSe layer. C-V profiling were tested on the DC bias from -0.15V to 0.3V. DLCP measurements were performed with AC amplitude from 20 mV to 140 mV and DC bias from -0.2V to 0.35V. In general, DLCP is sensitive only to free carrier density and bulk defects, while C-V tests is capable responding to free carrier density, bulk defects density and interfacial traps. From the plot, it is obvious that the N_{C-V} is only slightly higher than N_{DLCP} (only 1.5×10^{15} cm⁻³ at 305 nm, and 0.4×10^{15} cm⁻³ at 220 nm) comparing to the 1×10^{16} of reported result) indicating the major traps deteriorating the

photovoltaic performance of our devices were bulk defects. Bulk defects could be derived from composition variation induced point defects within the grains other than grain boundaries since large CZTSSe grains were obtained.



Figure S5. XPS spectra for S1, S2, S3 and their precursor film before annealing. The precursor film was spin-coated from hydrazine precursor and soft baked at 400 °C.



Figure S6. EDS line scan at the cross-section of sample annealed without S addition. A highly Cu rich, Sn poor elemental dispersion was observed at surface of the film, similar to the sample S1 with low S

addition. This result confirmed that proper S inclusion effectively optimized the surface constitution of CZTSSe film.

Variables for surface composition	S1	S2	S3				
Sn composition after SnS(e) lost	L	М	Н				
Zn enrichment by Sulfurization	М	Н	Н				
Sn increasing via SnS(e) deposition	М	М	L				
Cu	-	-	-				
Results	Cu rich, Sn poor	Cu poor, Sn rich	Cu poor, Sn rich				
Comments	Cu rich	Zn rich	Normal				
"L", "M" and "H" represent low, medium and high concentration in the film surface,							
respectively							

Table S2. Summarized factors for the surface composition variation of samples S1, S2 and S3.

References

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3. Heath, J.T., Cohen, J.D. & Shafarman, W.N., Bulk and metastable defects in CuIn1-xGaxSe2 thin films using drive-level capacitance profiling. *J. Appl. Phys.* **95**, 1000-1010 (2004).